



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of : **Confirmation No. 9938**
Hiroshi TAKANASHI et al. : **Docket No. 2001-0476**
Serial No. 09/838,118 : **Group Art Unit 1752**
Filed April 20, 2001 : **Examiner S. Lee**

**NEGATIVE-WORKING PHOTOSENSITIVE
RESIN COMPOSITION AND PHOTOSENSITIVE
RESIN PLATE USING THE SAME**

THE COMMISSIONER IS AUTHORIZED
TO CHARGE ANY DEFICIENCY IN THE
FEES FOR THIS PAPER TO DEPOSIT
ACCOUNT NO. 23-0975

PETITION FOR EXTENSION OF TIME

Assistant Commissioner for Patents,
Washington, DC 20231

Sir:

Petition hereby is made for a three month extension of time to respond to the communication of
August 14, 2002.

The fee of \$930.00 is

- ☒ submitted herewith.
☐ to be charged to Deposit Account No. 23-0975. A duplicate copy of this Petition is
enclosed.

☐ Small entity status of this application is established by a Small Entity Status Assertion
which
☐ is enclosed.
☐ has been previously submitted.

02/10/2003 SZEWDIE1 00000038 09838118

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930.00 00

Respectfully submitted,

Hiroshi TAKANASHI et al.

By Matthew Jacob
Matthew Jacob
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February 14, 2003

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